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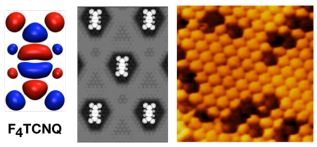
GraphicalAbstract



Highlights

- The interesting charge transfer effects between $F_4TCNQ(C_{12}F_4N_4)$ molecules and hexagonal boron nitride nanomesh (h-BN/Rh(111)) are demonstrated based on photoemission spectroscopy.
- Upon increasing molecular coverage, the work function of the $F_4TCNQ/h-BN/Rh$ system increases, indicating electron transfer from the substrate to the F_4TCNQ molecules.
- The σ_α and σ_β bands of the h-BN nanomesh shift towards lower and higher binding energy individually upon charging. The molecules prefer to adsorb inside of the pores.
- Density functional theory calculations indicate the lowest energy structure is doubly charged F_4TCNQ^{2-} in the nanomesh pores.
- F_4TCNQ molecules display high mobility and molecular "hopping" on the h -BN surface is observed at room temperature.

An electron acceptor molecule in a nanomesh: F_4TCNQ on h-BN/Rh(111)

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Abstract

The adsorption of molecules on surfaces affects the surface dipole and thus changes in the work function may be expected. The effect in change of work function is particularly strong if charge between substrate and adsorbate is involved. Here we report the deposition of a strong electron acceptor molecule, tetrafluorotetracyanoquinodimethane $C_{12}F_4N_4$ (F_4TCNQ) on a monolayer of hexagonal boron nitride nanomesh (h-BN on Rh(111)). The work function of the F_4TCNQ/h-BN/Rh system increases upon increasing molecular coverage. The magnitude of the effect indicates electron transfer from the substrate to the F_4TCNQ molecules. Density functional theory calculations confirm the work function shift and predict doubly charged F_4TCNQ^{2-} in the nanomesh pores, where the h-BN is closest to the Rh substrate and to have the largest binding energy. The preferred adsorption in the pores is conjectured from a series of ultraviolet photoelectron spectroscopy data, where the σ bands in the pores are first attenuated. Scanning tunneling microscopy measurements indicate that F_4TCNQ molecules on the nanomesh are mobile at room temperature, as "hopping" between neighboring pores is observed.

Keywords: electron acceptor, charge transfer, work function, h-BN, STM

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Introduction

Electron transfer is an essential process that governs many elementary processes in physics and chemistry. For atomic or molecular adsorbates on metallic surfaces simple arguments predict on whether an electron is transferred from the surface to the molecule or vice versa. The relevant quantities are the work function of the surface and on the other hand the ionisation potential or electron affinity of the atom or molecule: If the work function is larger than the ionisation potential, an electron is transferred to the metal substrate and the adsorbate charges positively. This effect is well known and e.g. used for surface ionisation of alkali metal atoms [1]. If the electron affinity is larger than the work function, an electron is transferred to the adsorbate from metal substrate [2]. For the case of surface ionisation it was pointed out by Gurney [3] that the quantum mechanical broadening of the adsorbate orbitals lead to the situation where the charge transfer is not complete and thus the electron tunnels back and forth between adsorbate and substrate. Also, the distance dependent interaction between substrate and adsorbate leads to a variation of the ionisation potential and the electron affinity, and the charge transfer itself changes the work function of the surface locally.

The charge transfer may be inferred from the dipole that is induced due to the charge transfer. If the adsorbate density is known, the induced dipole may be determined from the Helmholtz equation that relates a change of the work function $\Delta\Phi$ with the areal density n or coverage of the dipoles induced by the adsorbed species:

$$\Delta\Phi = -e\,\frac{p\,n}{\epsilon_0} \tag{1}$$

where e is the elementary charge, p is the induced dipole parallel to the surface normal, and ϵ_0 is the vacuum permittivity. From Eq. 1 we see that the work function decreases if the electron is transferred to the surface, and on the other hand increases if charge is transferred to the molecule.

If the metal surface is covered with a single layer graphite (graphene, g) [4, 5] or hexagonal boron nitride (h-BN)[6], the reactivity of the system changes. In

particular, the charge transfer time across the layer increases, and non-adiabatic effects may be observed [7].

The high electron affinity of the tetrafluorotetracyanoquinodimethane $C_{12}F_4N_4$ (F_4TCNQ) (see the chemical structure in Figure 1a) has made it to be an important electron acceptor molecule, with which anion formation on surfaces may be studied. Previously, Barja et al. reported self assembly of TCNQ ($C_{12}H_4N_4$) and F_4TCNQ ($C_{12}F_4N_4$) on the graphene/iridium system [8]. At low temperatures different adsorption geometries and electronic properties, depending on where the molecules were located in the g/Ir(111) unit cell [9].

The electron affinity of F_4TCNQ is 5.2 eV [10] and exceeds the work function of the h-BN/Rh(111) nanomesh [11] by 1.05 eV. Therefore we expect a complete electron transfer onto the molecule, and the formation of an open shell electronic system. This would open perspectives for spintronics as it was put forward for the TCNQ/g/Ru(0001) where long range magnetic order was found [12].

Here we report on F_4TCNQ on the h-BN nanomesh on Rh(111). We have investigated the system with photoemission spectroscopy and scanning tunnelling microscopy (STM) on the same preparations. Density functional theory (DFT) calculations complement the picture and come up with an unexpected prediction of structures with high adsorption energy and transfer of more than one electron onto the molecule.

The substrate for this study is the h-BN nanomesh on Rh(111)[13]. It features a corrugated single layer of boron nitride[14], where 13×13 BN units form a coincidence lattice on 12×12 Rh units with the nearest neighbour distances (Figure 1b). The 12×12 unit cell is constituted by 2 nm pores, where the nitrogen atoms are close to on-top Rh configuration, and where nitrogen lone pair bonding occurs [15]. These pores are separated by "wire" regions where the BN bonding to the substrate is weak. This pore-wire structure imposes strong *lateral* electrical fields (dipole rings) that are due to variations of the local electrostatic potential and that lead to to the self assembly of molecules in the pores [11]. The electrostatic landscape is such that negative charge is attracted to the pores, and accordingly we expect F_4TCNQ to first occupy the pores.

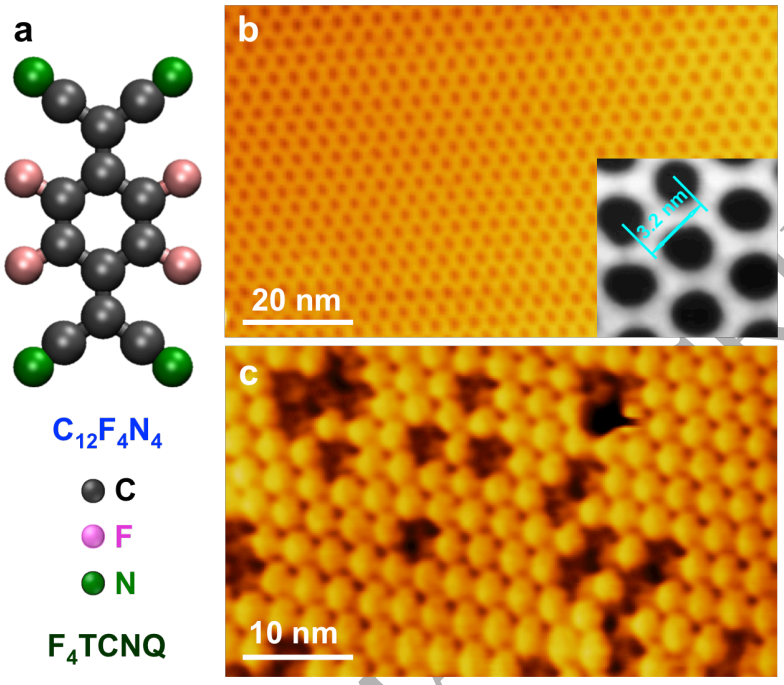

Figure 1: **F_4TCNQ on *h*-BN/Rh(111) surface.** (a) Ball and stick model of F_4TCNQ molecule ($C_{12}F_4N_4$). (b) and (c) Scanning tunnelling microscopy (STM) images at room temperature of pristine *h*-BN nanomesh on Rh(111). U_t = -1.20 V, I_t = 0.50 nA (b) and low coverage of F_4TCNQ molecules on *h*-BN/Rh(111) surface. U_t = 1.0 V, I_t = 0.3 nA (c). The right-bottom inset in (b) shows the supercell of *h*-BN nanomesh with a lattice constant of 3.2 nm. The wires appear bight and pores dark.

Results and Discussion

Figure 1b displays STM images of the pristine *h*-BN nanomesh on Rh(111) substrate with a superstructure lattice constant of 3.2 nm (shown in the inset of Figure 1b). In Figure 1c an STM image of the *h*-BN/Rh(111) nanomesh after a small dose of F_4TCNQ with less than 1 molecule per nanomesh unit cell is shown, which corresponds to the data point marked with green square in Figure 2a. "Bright" protrusions and "dark" depressions are imaged with the periodicity of the nanomesh. This imaging condition is obtained on a regular

base after scanning the surface for some time at room temperature. The picture resembles the STM image of F_4TCNQ on g/Ir(111), where the protrusions have been assigned to the molecules [8]. The ratio between dark and bright pores

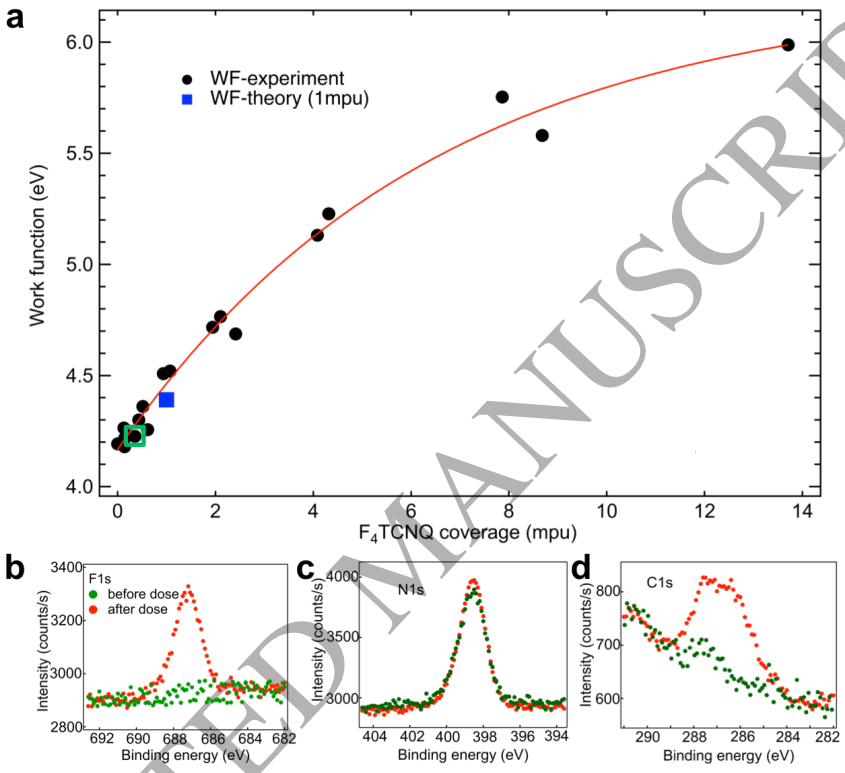

Figure 2: **Charge transfer between F_4TCNQ molecules and substrate.** (a) Work function increases with increasing the coverage of F_4TCNQ molecules. The black circles represent experimental data points with different F_4TCNQ molecular coverage, while the blue square indicates the calculated work function with F_4TCNQ coverage of 1 molecule per unit cell. The green open square corresponds to the STM data shown in Figure 1c. The red line is the fit of an exponential function as described in the text. (b)-(d) Mg Kα XPS ($\hbar\omega = 1253.6$ eV) spectra of F 1s (b), N 1s (c) and C 1s (d) before (green) and after (red) dosing F_4TCNQ on h-BN nanomesh. After adsorbing on h-BN surface, F_4TCNQ shows distinct feature on F 1s an C 1s core levels.

and comparison to the coverage as determined by XPS and the work function

shift of 80 meV that were measured on the same sample rather favors a picture where the dark pores correspond to pores that are occupied with a molecule.

Figure 2 shows the work function of the F_4TCNQ/h-BN/Rh(111) system as obtained from the width of He Iα excited normal emission ultraviolet photoemission spectra (UPS) as a function of molecular coverage. The coverage Θ in units of molecules per nanomesh unit cell (mpu) has been determined by Mg Kα excited x-ray photoelectron spectroscopy (XPS) intensity-ratios between the F 1s, the N 1s and the C 1s peaks and the corresponding atomic photoemission cross sections. As shown for a coverage of 7.8 mpu in Figure 2b-2d. Accordingly we find a coverage of one F_4TCNQ mpu at an atomic F:N ratio of 4:173.

As expected for an electron transfer to the molecules the work function increases with coverage. In fitting the data in Figure 2a to the function $\Phi = \Phi_0 + \Delta\Phi(1 - \exp(-\Theta/\Theta_0))$ we obtain the red line in Figure 2a and parameters $\Phi_0 = 4.2$ eV, $\Delta\Phi = 2.07$ eV, and $\Theta_0 = 6.4$ mpu. From this we see that at coverages below 2 mpu the work function increases linearly. The work function shift is much more pronounced than in the F_4TCNQ/g/SiC system where Chen et al. found an increase of 0.7 eV [16]. Given the fact that the work function of g/SiC is similar to that of h-BN/Rh(111) this is an indication that the binding of F_4TCNQ is different to h-BN on a metal from g on a semiconductor. For 1 mpu we obtain a work function shift of 0.3 eV at room temperature, and in cooling the sample to 185 K the work function further increases by 50 meV. The temperature dependent work function shift may be due to a higher occupancy in the pores. This numbers can be compared to the result from the DFT calculations, where we obtain a value $\Delta\Phi_{\mathrm{DFT,1\ mpu}}$ of 0.19 eV (as indicated with the blue square in Figure 2a). We consider this a very good agreement with experimental confirmation that at low coverage F_4TCNQ^- anions are formed on the h-BN nanomesh.

Figure 3 shows normal emission He Iα UPS excited valence band photoemission data of F_4TCNQ on h-BN/Rh(111) as a function of the coverage Θ. In Figure 3a a series of UPS spectra with different F_4TCNQ coverages from 0 to 4.3 mpu are shown. The spectrum with Θ=0 mpu is recorded after annealing

the clean nanomesh.

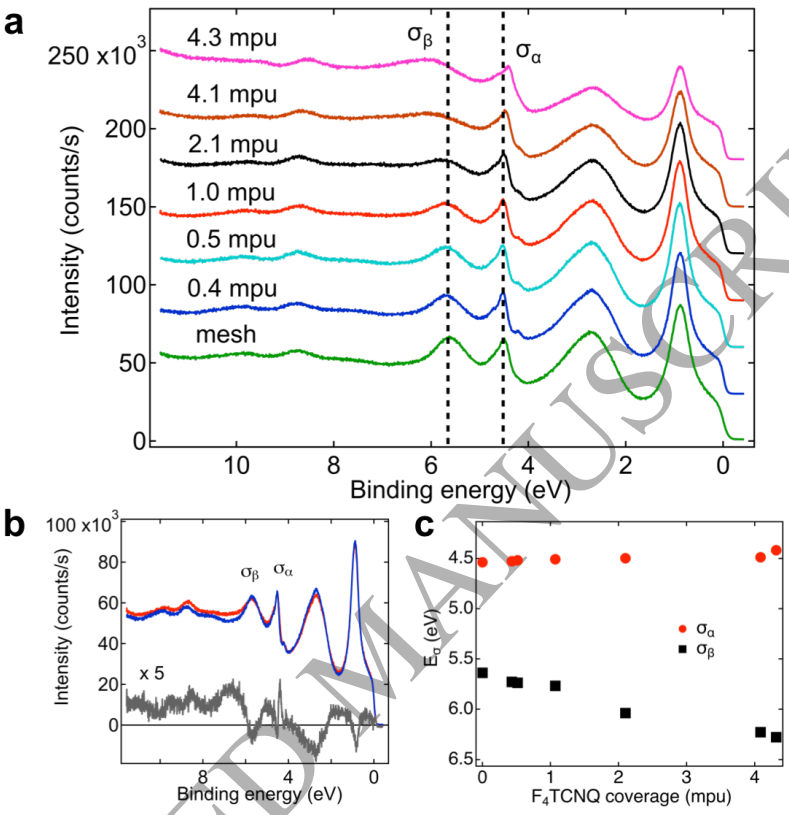

Figure 3: **He Iα normal emission ultraviolet photoemission spectrum (UPS) data of F_4TCNQ/h-BN/Rh(111).** (a) A series of UPS spectra of F_4TCNQ/h-BN/Rh(111) with different coverage of F_4TCNQ show that the σ_α and σ_β bands shift upon increasing of F_4TCNQ molecules. The two black dashed lines are a guide to the eye. (b) Comparison of UPS spectra of 0.4 molecule per unit cell (mpu) (blue) and 1.0 mpu (red). The grey plot is the difference between these two spectra (1.0 mpu-0.4 mpu). In order to better demonstrate the difference, the grey horizontal zero line is added, and the data is scaled by a factor of 5. Clearly, the σ_α and σ_β bands are affected by adding more F_4TCNQ molecules, where the σ_β band decreases significantly. This indicates that F_4TCNQ molecules predominantly occupy the pores, but shift as well the wire potential. (c) Shift of peak positions of σ_α and σ_β bands with the increase of F_4TCNQ molecules. The σ_α band shifts towards lower binding energy, while the peak in the σ_β band-region shifts to higher binding energy.

Afterwards F_4TCNQ has been evaporated successively and measured with XPS and UPS after each evaporation. The spectra are dominated by the well-known valence band pattern of h-BN/Rh(111) with the Rh 4d valence band peak at 0.88 eV binding energy, and the split h-BN σ-band [14]: σ_α that accounts for the electronic structure in the nanomesh wires and σ_β for that in the nanomesh pores [17].

Like it was first shown for naphthalocyanine on h-BN nanomesh [14] and later for Xe on h-BN nanomesh [11], adsorbates attenuate the photoemission signals from the substrate, and since the signal from the pore, σ_β is attenuated before the signal from the wires σ_α, a higher adsorption energy in the pores was concluded for naphthalocyanine and for 12 Xe atoms in the pores. Here we observed the same trend: With increasing molecular coverage the σ_β intensity decreases before it does the σ_α intensity. In Figure 3b the spectra of 0.4 mpu and 1.0 mpu are compared, and the difference between the two (1.0 mpu - 0.4 mpu) is displayed after scaling by a factor of 5. The above-said is confirmed, in particular the attenuation effect is also seen for the Rh substrate peaks.

The assignment of molecular orbitals is not possible at these low coverages, photon energy and emission angle. We observe, however, a shift in binding energy for the boron nitride related σ bands. The sharpest feature in the difference curve lies at the steep onset of the σ_α band at 4.39 eV binding energy and it is accompanied by a sharp negative peak at 4.53 eV. This indicates a σ_α band shift to lower binding energy with increasing coverage and is remarkable since the majority of the molecules must sit in the pores as it is indicated by the attenuation of the σ_β intensity. The spectral weight near the broader σ_β peak appears to shift towards higher binding energies with increasing coverage. This may be related to the decrease σ_β intensity and the increase of F_4TCNQ derived molecular orbitals at around 7 eV binding energy. In Figure 3c the binding energy positions of the σ_α band and the local maximum near the σ_β band are shown as a function of the F_4TCNQ coverage. For flat h-BN the sigma bands are known to align with the vacuum level and to lead to the "physisorption model" [6], where on the Rh(111) substrate the σ_α band has the same offset of

about 9 eV from the vacuum level like Ni, Pd and Pt. Therefore it is expected that with increasing work function the σ_α energy rises. The fact that the rise of 14 meV per mpu does not correspond to the 300 meV per mpu indicates again that the vast majority of the F_4TCNQ molecules are not adsorbed on the wires. The shift in σ_β band of -161 meV per mpu may not be explained with the *h*-BN "physisorption model" of Nagashima et al. [6]. It rather indicates that the F_4TCNQ^- molecules influence the boron and the nitrogen atoms in the pore, and the above-mentioned photoemission intensity redistribution between σ_α and F_4TCNQ molecular orbitals that may impose as well an apparent shift.

Figure 4 shows STM images of a sample with low coverage measured with variable temperature (VT)-STM system. As mentioned above, low coverage of

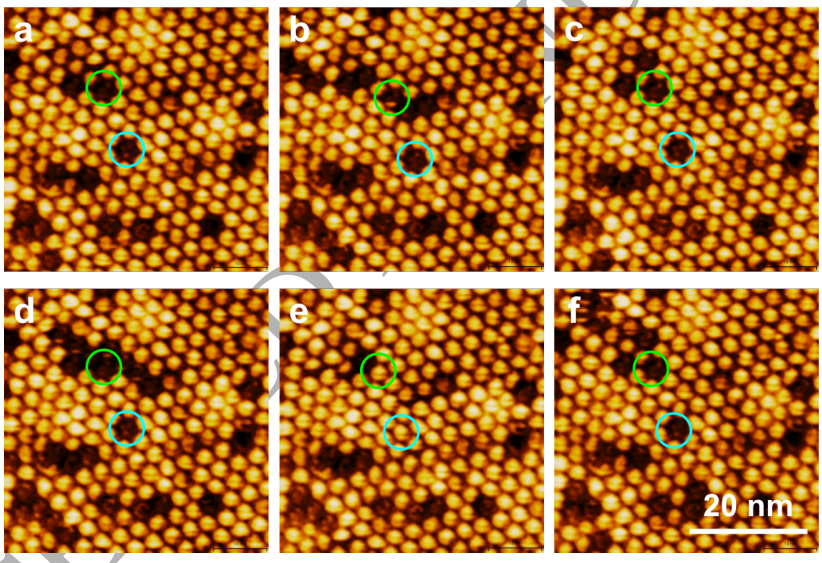

Figure 4: **F_4TCNQ "hopping" at low coverage below 1 molecule per unit cell.** (a)-(f) A series of sequential STM images of F_4TCNQ on *h*-BN/Rh(111) with low coverage at the same area with the same scanning conditions show the F_4TCNQ molecules "hopping" (appear and disappear) on the surface at room temperature. The green and blue circles represent the same positions in every image to guide the eye. The time interval between two subsequent frames is 125 s. The contrast between dark and bright, as derived from the histogram of the z-values of panel (d) is 2.6 Å, U_t = -1.0 V, I_t = 0.005 nA.

F_4TCNQ/h-BN/Rh(111) displays "bright" and "dark" features on the h-BN surface at room temperature, which are confirmed by two different instruments, i.e., ESCA (Park Scientific) (Figure 1c) and VT-STM (Figure 4). Figures 4a-4f illustrate a sequences of continuous scanning of the same area with same scanning conditions, where the time intervals between the images is 125 s. The green and blue circles in each image indicate the same positions individually in order to guide the eyes. The 6 STM images in Figure 4a-4f evidently demonstrate F_4TCNQ "hopping" on the h-BN surface at room temperature. For instance, the "dark" depressions marked with green and blue circles in Figure 4d appear to be "bright" protrusions in the Figure 4e, while the same positions show the "dark" features again in the subsequent Figure 4f. In order to demonstrate more "hopping" events and in a longer time scale, we made a movie with 40 continuous STM images scanning with same condition on the same area in the Supporting Information. This "hopping" feature indicates the high mobility of F_4TCNQ molecules on h-BN surface, which is similar to the case of F_4TCNQ on g/Ir, where the F_4TCNQ molecules were reported to "rotate" even at 77 K [8].

To better understand the experimental results, we carried out DFT calculations. DFT confirms that the F_4TCNQ molecules like to sit in the pore of the h-BN nanomesh. The theory predicts the work function change and the charge transfer upon adsorption of one mpu. In Figure 5 the two lowest energy structures in the nanomesh pores are depicted. They are significantly distinct to each other, in binding energy, charge transfer, work function change and coordination to the beneath h-BN. In reference to the charge transfer the two structures are labeled as "1-" and "2-". Intriguingly, the work function change of "2-" is smaller than that of the "1-" structure, which must be related to the onset of covalent chemisorptive bonds and gain of exchange energy in the lowest unoccupied molecular orbital of the neutral molecule (LUMO) for "2-", which apparently superseeds the Coulomb repulsion in the LUMO. On the other hand "1-" is more physisorptive with ionic and van der Waals bond character and an open LUMO shell. The work function change of 0.19 eV per mpu of

the lowest energy "2-" structure fits well to the experimental result of 0.3 eV. Though, from the experiment we find no direct arguments on the charge state of F_4TCNQ on h-BN nanomesh. Rather, the high DFT binding energy difference between molecules in the pore and on the wire (see Table 1), would not suggest much diffusion as we observe it at room temperature.

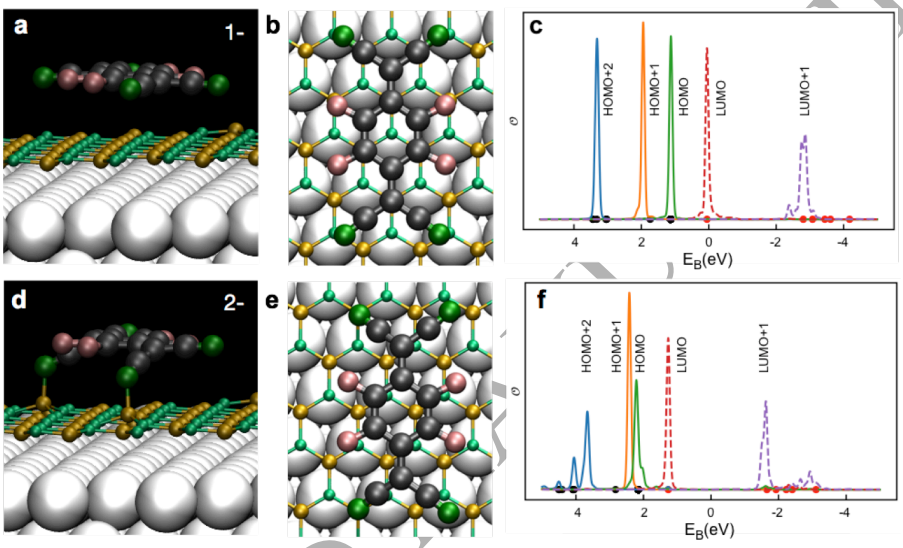

Figure 5: **DFT results of two different F_4TCNQ structures in the h-BN/Rh(111) nanomesh pores.** (a-c) The "1-" structure with one electron transfer. (a) Perspective view showing a floating molecule, (b) top view: The molecule is centered on top of the h-BN nitrogen atom with on top of Rh coordination and (c) the orbital overlap $\mathcal{O}$ with the LUMO pinned at the Fermi level. (d-f) The "2-" structure with two electron transferred, which has a 26 % higher binding energy than "1-". (d) Perspective view, showing the covalent bonding of two cyano (CN) groups to two boron atoms which get pulled off the h-BN layer. (e) Top view: The molecule is shifted away from the pore center such that two CN-B bonds become operational and (f) the orbital overlap $\mathcal{O}$, where the LUMO lies below the Fermi level. Note that the distinct distortion of the molecules imposes a non-rigid shift of the molecular orbital energies. The solid sycircles in (c) and (f) are the gas phase eigenvalues. Color code for atomic models: Boron orange, carbon black, fluorine pink, nitrogen green, rhodium whitish.

We have to speculate on how the detailed hopping mechanism as we observe it (see Figure 4) operates: Possibly the STM imaging process triggers hopping events. In Figure 5c and 5f the orbital overlap $\mathcal{O}$, or the projection of the Kohn-Sham electronic states of the adsorption system on the molecular orbitals of a single molecule (but in the geometry as adsorbed) is shown for "1-" and "2-". The orbital overlap indicates at which energies the molecular orbitals reside when adsorbed, and if there are large changes, for example due to hybridisation. There are clearly defined states, in particular the HOMO-1, HOMO and LUMO, and the states above the LUMO are separated, like for the molecule in the gas phase. The gas phase eigenvalues are indicated with solid circles: Black for the occupied orbitals, and red for unoccupied ones. The energy alignment between gas phase and adsorbate system is arbitrary, and done to fit the HOMO and LUMO reasonably well. In the structure "F_4TCNQ^{2-}", where the Bader charge of the molecule is close to -2 e, the two fold degenerate LUMO of the gas-phase molecule is clearly below the Fermi energy, thus agreeing with the charge state "2-". Instead the charge state of "F4-$TCNQ^{1-}$" seems to pin at the Fermi level, would indicate half filling and display a magnetic moment. 1.

Table 1: Calculated work functions Φ for 5 different structures. The binding energies E_{bind} for 4 different molecular conformations and the Bader charges on the molecules $q_{Bader,molecule}$ for the 3 single molecule structures.

System	E_{bind} (eV)	Φ (eV)	$q_{\text{Bader,molecule}}$ (e)
clean	—	4.20	—
1-	3.07	4.61	-1.34
2-	4.15	4.39	-1.89
wire	1.78	4.88	-0.40
dimer (pore)	3.64	4.88	

In Table 1 we also show the binding energy for a F_4TCNQ^{2-} dimer. It is significantly lower than that of two molecules in two different pores. From this

we expect single pore occupancy to be the lowest energy structure.

Conclusions

In conclusion, combining controlled experimental photoemission and scanning tunneling microscopy measurements with density functional theory calculations, we demonstrate electron transfer from h-BN/Rh(111) to F_4TCNQ. As negatively charged molecules (electron acceptors) coalesce on the surface, the work function of the system increases. Upon charging, the σ_α and σ_β bands of h-BN nanomesh shift towards lower and higher binding energy, individually. The molecules preferably occupy the pores of the h-BN/Rh(111) nanomesh, though display mobility and molecular "hopping" on the h-BN surface at room temperature. DFT results indicate that the lowest energy structure is an anionic "2-" species. Our work pave the way to tune the electronic and structural properties of two-dimensional materials by using organic molecules adsorptions.

Methods

Experimental

The experiments were performed in two ultrahigh-vacuum (UHV) systems with base pressure of 1×10^{-10} mbar. One is a variable-temperature STM (Omicron VT-STM), and the other is a user-modified Vacuum Generators ESCALAB 220 with a Mg Kα lab source at an energy of $\hbar\omega = 1253.6$ eV, with a monochromatized He Iα ($\hbar\omega = 21.2$ eV) source equipped with a room-temperature STM (Park Scientific) that allows photoemission and STM measurements on the same sample [18, 19]. The work function has been determined from the width of the He Iα photoemission spectrum recorded at a sample bias of -9 V. The STM measurements were carried out with electrochemically etched tungsten tips. All STM images were taken in constant-current mode at room temperature. At negative tunneling voltages U_t electrons are tunneling from the substrate to the tip. The h-BN/Rh(111) samples were produced with the standard recipe [13]. Particularly purified F_4TCNQ molecules were evaporated

on h-BN/Rh(111) substrates kept at room temperature using a Knudsen cell at 365 K. Then the samples were transferred to the analysis chambers for the photoemission or the STM measurements.

Theory

Calculations were performed using the Kohn-Sham DFT formalism within the Gaussian plane wave (GPW) method [20] as implemented in the QuickStep module [21] in the CP2K program package [22]. The exchange-correlation term was approximated with the rB86-vdW-DF2 exchange-correlation functional [23] that explicitly includes the van der Waals interactions. In the GPW scheme we used the expansion of the molecular orbitals with Gaussian basis functions [21], and the electron density is expressed with a plane wave basis set up to 700 Ry with a relative cut-off of 70 Ry. Dual-space pseudopotentials [24] were used to describe the interaction of valence electrons with atomic cores. We sampled the first Brillouin zone at Γ point only. The theoretical lattice constant of Rh of 3.8147 Å was employed in the calculations. The substrate was modelled with four layers of Rh(111), of which the two lowest were kept fixed at their bulk positions during the relaxation.

Conflict of Interest

The authors declare no competing financial interest.

Acknowledgements

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